## Coexistence of two different mechanism of dynamic nuclear polarization in a transition region between integer quantum Hall states

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In the quantum Hall states (QHS) of semiconductor two-dimensional electron gas, the hyperfine coupling between electron spin and nuclear spin has been utilized for polarizing and detecting the nuclear spins. Up to now, there have been two different processes to polarize nuclear spin; these are edge channel (EC) and bulk states (BS) of QHE. These two processes had been treated as independent method to control nuclear spins. However, since the nature of QHE, these two contributions can not be completely separated and could be coexisting depending on device geometry. We compared current induced dynamic nuclear polarization (DNP) in Hall bar device in longitudinal resistance (LR) and non-local resistance (NLR) configuration and revealed coexisting of EC and BS contribution.

The 2-dimentional electron gas (2DEG) in GaAs/AlGaAs is patterned into the Hall bar device. At the filling factor  $\nu=1.7$  of the QHS, the differential NRL  $R_{\rm NL}$  and LR  $R_{\rm xx}$  is measured under dc-current bias  $I_{\rm SD}$  as shown in top panel of Fig. 1 and 2, respectively. We observed clear hysteresys between up and down sweep due to the polarization of nuclear spins. We determined the magnitude of DNP using pump-probe measurements where we pumped nuclear system with various  $I_{\rm SD}$  for 200 second and probed the nuclear spin states at  $I_{\rm SD}$ =0. The difference of  $R_{\rm xx}$  at  $I_{\rm SD}$ =0 before and after the pumping is derived as  $\Delta R$  and obtained  $I_{\rm SD}$  dependence of  $\Delta R$  is plotted on the bottom panel of Fig. 1 and 2, respectively. The  $\Delta R$  vs.  $I_{\rm SD}$  can be viewed as a superposition of symmetric and asymmetric dependence on  $I_{\rm SD}$ . We compared  $\Delta R_{\rm xx}$  and  $\Delta R_{\rm NL}$  with various contact configuration and external field direction. Results indicate that these asymmetric and symmetric contributions can be explained by the DNP induced by the EC and BS, respectively. And these two contributions coexist in Hall bar device.

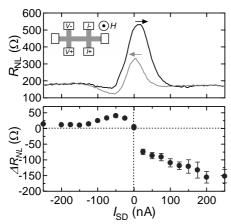


Fig. 1:  $I_{SD}$  dependence of  $R_{NL}$  and  $\Delta R_{NL}$ .

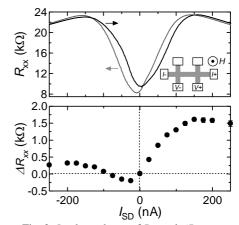


Fig. 2:  $I_{SD}$  dependence of  $R_{xx}$  and  $\Delta R_{xx}$ .

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